

UNITED STATES PATENT AND TRADEMARK OFFICE

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| APPLICANT(S) | Dunn | GROUP ART UNIT: | 2814 |
| APPLN. NO.: | 10/743,589 | EXAMINER: | Hoa B. Trinh |
| FILED: | Dec. 22, 2003 | Confirmation No. | 7968 |
| TITLE: | TWO-LAYER PATTERNED RESISTOR | | |

AMENDMENT

This amendment is being filed electronically
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated February 3, 2006, please amend the above-identified application as follows: